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Article

A Comprehensive Study on the Effect of Defects on Perovskite Solar Cell Performance

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Abstract: This paper focuses on the impact of defects density and carrier capture cross-section area in the electron transport material (ETM), hole transport material (HTM), and absorber layers on the performance of perovskite solar cells and quantum efficiency (QE). Furthermore, the impact of defects density at the interface between ETM/absorber and absorber/HTM is also studied. SCAPS-1D software is used in the current study in determining solar cell performance. The proposed perovskite solar cell structure is a planar FTO/TiO₂/CH₃NH₃PbI₃/Cu₂O. The results indicated that increasing the defect density in the absorber layer significantly affects cell performance, while in ETM and HTM layers, the cell parameters remain unaffected. It is also found that the defect capture cross-section has a similar behavior to the defect density in the main layers (ETM, absorber, and HTM). In addition, it is observed that by increasing the defects density in the ETM/absorber and absorber/HTM interfaces layer, the cell parameters FF, J_{sc}, and PCE have been slightly decreased, with no effect on V_{oc}. Moreover, it is also noted that the quantum efficiency QE is sharply reduced. Finally, this paper introduced the correlation between the defect density and the capture cross-section, which is the first attempt to find such a relationship in perovskite solar cells to the knowledge of the authors.

Keywords: defect density; capture cross-section; perovskite solar cell; SCAPS; interfaces

1. Introduction

Hybrid mix halide perovskite solar cells (PSC) have risen to prominence due to the unique properties of the absorber, such as elevated charge carriers' mobility, wide and high absorption coefficients, long carrier diffusion duration, and low electron-hole binding energy, low cost, and ease of manufacturing [1], [2]. PSCs have imposed them-selves as an important photovoltaic (PV) technology, competing with silicon-based cadmium telluride solar cells and copper indium gallium selenide solar cells [3]. This remarkable advancement in efficiency PCEs is largely a result of architectural optimization, the application of interface engineering, the development of electron and hole transport components, and the improvement of fabrication processes using elevated-quality perovskite films [4]. Over the last few years, a new group of solar cells based on perovskites with mixed halides has emerged at an unprecedented rate. In 2009, it was discovered that perovskite substances exist in solar panels with a power conversion efficiency (PCE) of no more than 4% [5]. Perovskite materials, such as methylammonium lead iodide (MAPbI₃), exhibit a variety of intrinsic defects due to vacancies, antisites, and interstitial defects. Numerous studies have investigated the effect of defect density on the efficiency of hybrid mixed perovskite solar cells [6]. How-ever, no exhaustive study is available at this moment that fully studies the impact of defects taking into account all aspects. A thorough understanding is thus required to make Perovskite solar cells competitive with conventional solar cell technology. Classification of defects is possible according to their position in the band gap energy, where they can be discovered at either a deep level or shallow level [6]. SCAPS-1D software package was used to study the effect of defects density of the active layer and n/i interface of PSCs as a function of cell thick-ness [7]. Au/PEDOT: PSS/Perovskite/CdS/TCO/Glass was used to define the planar p-i-n configuration, and its performance was simulated where a power conversion efficiency of >25% can be achieved. It was discovered that defects density harms the performance of PSCs. The im-pact of the defect in the CH3NH3PbI3 layer was deter-mined using optical and structural properties analysis and structure as FTO/WO₃/CH₃NH₃PbI₃/Spiro-OMeTAD/Au [8]. The absorber layer thickness has been changed to determine the optimal cell parameter values. The purpose of this paper is to examine the impact of defects in the PSC structure on the following: Glass/FTO/TiO₂/CH₃NH₃PbI₃/Cu₂O/metal back contact, which is simulated using the solar cell one-dimensional capacitance simulation (SCAPS-1D). The work investigates the effect of defects on the performance of the PSC and the quantum efficiency QE, with a particular emphasis on the capture cross-section area and defects density in the ETM and HTM, and absorber layers as well as in the interface layers. In addition, the impact of defect level and defect type on quantum efficiency will be studied, and compared the behavior of Cu₂O with CuI and Spiro-OMeTAD as HTM material.

2. Device structure and parameters

SCAPS 1D program is used in this study since it is wide-ly regarded as among the most efficient and user-friendly simulation tools for modeling solar cells. The proposed perovskite solar cell structure is a planar structure com-posed of glass/FTO/TiO₂ (ETM layer)/CH₃NH₃PbI₃ (active layer)/(HTM layer)/metal back contact as illustrated in Figure 1. The simulation parameter values are listed in Table 1 based on data from the literature. The defect parameters of the CH₃NH₃PbI₃ absorber layer and the ETM/absorber and HTM/absorber interface of the PSCs are summarized in Table 2.

Table 1. Simulation	parameters	of Perov	vskite s	olar o	cells	devices	[9]	<u> - </u>	[12]	

Parameter	FTO	TiO ₂	CH ₃ NH ₃ PbI ₃	Cu ₂ O
Thickness(μ m)	0.5	0.05	0.4	0.4
The band gap (eV)	3.5	3.2	1.55	2.17
Electron affinity (eV)	4	3.9	3.9	3.2
Dielectric permittivity(relative)	9	9	6.5	6.6
CB effective density of state (1/cm³)	2.2 ×10 ¹⁸	1 ×10 ²¹	2.2 ×10 ¹⁸	2.5 ×10 ²⁰
VB effective density of state (1/cm³)	1.8 ×10 ¹⁹	2×10 ²⁰	1.8 ×10 ¹⁹	2.5 ×10 ²⁰
Electron Mobility (cm ² /Vs)	20	20	2	80
Hole Mobility (cm ² /Vs)	10	10	2	80
Donor density ND (1/cm ³)	2×10 ¹⁹	1×10 ¹⁹	0	0
Acceptor density NA (1/cm ³)	0	1	1×10 ¹⁵	3×10 ¹⁸
Electron thermal velocity (cm/s)	1× 10 ⁷	1× 10 ⁷	1× 10 ⁷	1× 10 ⁷
Hole thermal velocity (cm/s)	1× 10 ⁷	1× 10 ⁷	1× 10 ⁷	1× 10 ⁷

Table 2. The parameters of defects in the absorber and interface layers.

Parameter	Defect of ab- sorber	Defect of HTM/ab- sorber	Defect of ETM/ absorber
Defect type	Neutral	Neutral	Neutral
Capture cross section of electrons (cm ²)	2×10-15	2×10 ⁻¹⁵	2×10 ⁻¹⁶
Capture a cross-section of holes (cm ²)	2×10 ⁻¹⁵	2×10 ⁻¹⁵	2×10 ⁻¹⁶

Energetic distribution	Gaussian	Single	Single
Characteristic energy (eV)	0.1	0.1	0.1
Energy with respect to a reference (eV)	0.5	0.65	0.65
Total density (1/cm ²)	$(10^{10} - 10^{18})$	1×10 ¹⁸	1×10 ¹⁸

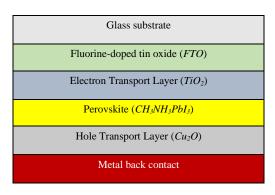


Figure 1. The basic structure of the perovskite solar.

Other parameters include the defects density in the CH₃NH₃PbI₃ layer, which is set to (2.5×10^{13}) cm⁻³ using a Gaussian energetic distribution, and the defect densities N_t in other layers, which is set to 10^{15} cm⁻³ and the absorber coefficient is set to 10^5 cm⁻¹, while the absorber layer's absorption α is set to (1.5×10^5) cm⁻¹ [13]. The simulation makes use of the spectrum generated under standard conditions (air mass AM1.5 G, temperature 300 K). The voltage is ranged between 0 and 1.3 V. The reference cell's current-voltage characteristics (J-V) based on Cu₂O as HTM is shown in Figure 2. The performance parameters for the reference cell that is based on Cu₂O and given as PCE = 17.72%, FF =77.23%, J_{sc} = 22.54 mA·cm⁻², and V_{oc}= 1.01 V.

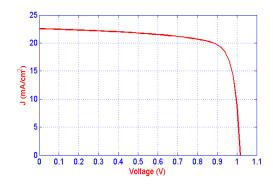


Figure 2. The J-V characteristics of the reference cell with Cu₂O as HTM layer.

3. Result

3.1. The influence of defect density in the absorber layer with Cu2O as the HTM layer

To investigate the effect of defect density in the MAPbI $_3$ layer on performance parameters, the defect density of photovoltaic cells was varied between 2.5×10^{10} cm $^{-3}$ and 2.5×10^{18} cm $^{-3}$, while maintaining other parameters un-changed such as capture cross-section in absorber layer equals to 2×10^{-15} cm 2 . Total density in both interfaces HTM and ETM are set to 10^{18} cm $^{-2}$. The defect energy level is set to 0.5 eV above the valance band as shown in Figure 3.

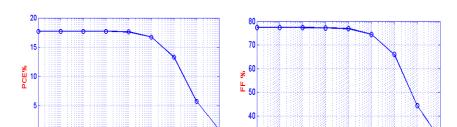


Figure 3. Variation of defects density in absorber layer with Cu_2O as HTM layer on PSC parameters: (a) PCE, (b) FF, (c) J_{sc} , (d) V_{oc} .

As it is shown in Figure 3a, the PCE dropped rapidly from 17.60 % to 0.86 % with increasing the defects density from 2.5×1015 cm⁻³ to 2.5×1018 cm⁻³. Additionally, if the defects density is less than 2.5×10¹⁵ cm⁻³, the PCE keeps the same as the change is about 17.73 %. Furthermore, if the defects density is greater than 2.5×10¹⁵ cm⁻³, the FF falls from 74.47 % to 30.18 % as depicted in Figure 3b. It can also be observed that when the defects density is less than 2.5×1015 cm⁻³, the FF has remained nearly un-changed at around 77.27%. The J_{sc} and V_{oc} are presented in Figure 3c and Figure 3d, respectively. It can be observed that the V_{oc} drops from 1.01 V to 0.67 V with increasing the defects density from 2.5×10¹⁵ cm⁻³ to 2.5×1018 cm⁻³. However, the V_{oc} wasn't significantly changed when the defects density is lower than 2.5×10¹⁵ cm⁻³. Furthermore, the J_{sc} falls quickly from 22.45 mA.cm⁻² to 4.23 mA.cm⁻² as the defect's density is higher than 2.5×10¹⁵ cm⁻³. How-ever, when the defect density is less than 2.5×1015 cm-3, the Jsc is unchanged at 22.54 mA.cm-2, and the defect density is near the center of the band gap. The increased number of traps had a defects density greater than 2.5×10¹⁵ cm⁻³, due to a significant decrease in J_{sc}. This is highly consistent with numerous studies, demonstrating that defects in the MAPbI3 absorber layer have a significant effect on the cell's performance [14-16].

3.2. The effect of capture cross-section in the absorber layer with Cu2O as HTM layer

The impact of *electron* σ_n and hole σ_P capture cross-section in MAPbI $_3$ layer on perovskite cell is investigated by varying the capture cross-section area value from 2×10^{-10} cm $_3^2$ to 2×10^{-18} cm $_3^2$. The defect level is set to 0.5 eV above the valance band, while other parameters are kept constant such as defects density in the absorber layer, which is set to 2.5×10^{13} cm $_3^2$. The total density in both interfaces HTM and ETM are set to 10^{18} cm $_3^2$. The results are illustrated in Figure 4.

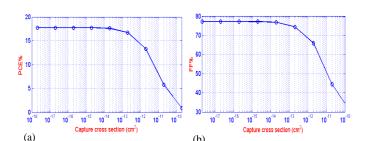


Figure 4. The change of cell performance: (a) PCE, (b) FF, (c) J_{sc} , (d) V_{oc} versus the capture cross-section in the absorber layer with Cu_2O as HTM layer.

As it is shown in Figure 4a, when the value of the capture cross-section area in MAPbI $_3$ is greater than 2×10^{-13} cm 2 , the PCE is reduced sharply from 16.73 % to 0.86 %. In addition, when the capture cross-section area is set to be smaller than 2×10⁻¹³ cm², the PCE is kept unchanged at 17.73 %. Furthermore, if the capture cross-section is great-er than 2×10⁻¹³ cm², the PCE is decreased to about 0.86 %. The change of FF versus the capture cross-section in the MAPbI3 absorber layer is shown in Figure 4b, where FF varies slightly from 77.27 % to 76.89 %, due to the capture cross-section, which is less than 2×10⁻¹³ cm². Once the capture cross-section reaches 2×10⁻¹³ cm², the FF drops rapidly with the increase of the capture cross-section. As with other parameters, it is found that the Jsc changes slightly when the value of the capture cross-section is smaller than 2×10⁻¹³ cm². The J_{sc} decreases significantly from 22.45 mA.cm⁻² to 4.23 mA.cm⁻², as the capture cross-section area increases gradually from 2×10⁻¹³ cm² to 2×10⁻¹⁰ cm². At the capture cross-section area of 2×10⁻¹⁰ cm², the J_{sc} is approximately 4.23 mA.cm⁻². If the capture cross-section in the MAPbI₃ layer increases from 2×10⁻¹³ cm² to 2×10⁻¹⁰ cm², the V_{oc} decreases from 1.01 V to 0.67~V. In addition, the V_{oc} is kept unchanged when the capture cross-section area is set to be smaller than 2×10⁻¹³ cm². To describe this theory, it is generally known that the carrier lifetime is strongly dependent on capturing cross-sections and the defect trap density. The capture cross-section depicts the probability of the trap catching the free carried item, thereby increasing the capture cross-section area for electrons and holes resulting in a decrease of a lifetime, as well as efficiency, fill factor, current density, and open circuit voltage. It is a good match to the recent research indicating that defects in the absorber layer have a significant impact on the cell's performance [17], [18]. Increasing the defects density and capture cross-section area within the selected range as it is shown in reference results in cell performance parameters: PCE = 17.72%, FF =77.23%, J_{sc} = 22.54 mA·cm⁻², and V_{cc} = 1.01V. The increase of the defects density and capture cross-section have shown no impact on the performance parameters of the PSC in HTM and ETM layers. To ex-plain this, the role of the hole transportation layer HTM and electron transportation layer ETM is only to extract and convey the collected holes and electrons from the absorber region. Thus, there will have no significant im-pact.

3.3. The effect of defect density in HTM and ETM interface layers

In the suggested structure of the cell, two interfaces were presented: (ETM/absorber) and (absorber/HTM), and the effect of defects density in the ETM/absorber and absorber/HTM interface layers on the cell's performance was examined. The defect parameters for both interface layers are previously summarized in Table 2.

Firstly, the impact of defects density in the HTM/MAPbI₃ interface layer on the cell parameters is studied where there was a variation in the defect density from 10¹¹ cm⁻² to

 10^{20} cm⁻². The defect energy level is set to 0.5 eV above the valance band, while other parameters are kept un-changed such as defect density, which is set to 2.5×10^{13} cm⁻³, and the capture cross-sectional in the MAPbI₃ layer is set to 2×10^{-15} cm². The results are depicted in Figure 5.

Figure 5. The vary of cell performance parameters (a) PCE, (b) FF, (c) J_{sc} , (d) V_{oc} versus the defect's density in the Cu₂O/ absorber layer.

As it is shown in Figure 5, the performance parameters changed slightly with the increase in the defect's density. When the defect densities varied from 10^{11} cm⁻² to 10^{14} cm⁻², the PCE was reduced slightly from 18.4% to 17.74%. Once the defect density reaches 10^{14} cm⁻², the PCE keeps constant at about 17.72%. In addition, when defect density is set to be greater than 10^{14} cm⁻², the FF remains un-changed at about 77.24%. Whereas once the defect density is set to be lower than 10^{14} cm⁻², the FF reduces slightly from 78.54% to 77.29%. Moreover, if the defect density is set to be less than 10^{14} cm⁻², the J_{sc} decreases slightly from 22.67 mA.cm⁻² to 22.45 mA.cm⁻² with the increase of the defect's density. In contrast, the V_{oc} is relatively unchanged and remains around 1.01V with the increase of the defect's density. It can be observed that the variation of the defects density has an insignificant effect on HTM/MAPbI₃ interface layer on perovskite solar cell devices.

The impact of defect density in MAPbI₃/TiO₂ interface layer on cells performance parameters PCE, FF, J_{sc} , and V_{oc} has also been investigated by changing the defect density from 10^{11} cm⁻² to 10^{20} cm⁻². The defect energy level is set to 0.5 eV above the valance band, while other parameters are fixed unchanged such as defect density equal to 2.5×10^{13} cm⁻³, and the capture cross-section area in the absorber layer is set to 2×10^{-15} cm². The results are shown in Figure 6.

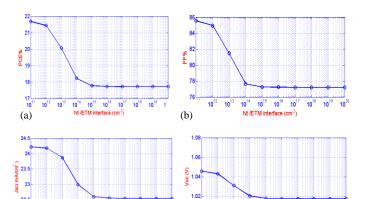


Figure 6. Performance parameters (a) PCE, (b) FF, (c) J_{sc} , (d) V_{oc} . versus defect density in the interface of absorber/ETM with Cu₂O as HTM layer.

As it is shown in Figure 6, the PCE reduces slightly from 21.68% to 17.73% when the defects density in MAP-bI₃/ETM layer increases from 10¹¹ cm⁻² to 10¹⁵ cm⁻². It can also be seen that the PCE has remained unchanged (about 17.72%) when the defects density is set to be higher than 1015 cm⁻². The FF decreased slightly to 8.35% when the defect density was below 1015 cm-2. Maximum FF is achieved around 85% when the defects density is set equal to 10¹¹ cm⁻². When the defect density is greater than 10¹⁵ cm⁻², the FF remains constant at about 77.23%. The Jsc in MAPbI₃/TiO₂ interface is kept unchanged (around 22.54 mA.cm⁻²) as the defect's density is set higher than 10¹⁵ cm⁻². In addition, it can be observed that the J_{sc} de-clines slightly from 24.22 mA.cm⁻² to 22.55 mA.cm⁻² when the defects density increases from 1011 cm⁻² to 1015 cm⁻². In addition, when the defects density varies within the mentioned range, the open circuit voltage V_{oc} remains constant at about 1.01 V. From the result, it can be noticed that the defect density in MAPbI₃/ETM interface layer has a trivial impact on PCE, FF, and Jsc, while it does not affect Voc at all. To explain this, the performance of the cells is suffering a slight reduction, due to the ETM and HTM interfaces being described as defects with the increase of the defect's density within the tested range

3.4. The effect of defects density on photovoltaic performance in MAPbI3 absorber layer for all cells.

To evaluate the impact of defects density in MAPbI $_3$ layer on cells parameters for different hole transport mate-rial HTM, such as Cu $_2$ O, CuI, and Spiro-OMeTAD, normalized results are produced to compare the performance with the existing of each material. This comparison gives a deeper physical insight to understand the impact of changing the HTM layer at different defect densities. The studied defects' densities varied from 10^{10} cm $^{-3}$ to 10^{18} cm $^{-3}$. The defect level is set to 0.5 eV above the valance band while maintaining other parameters unchanged, such as capture cross-section in the absorber layer, which is set to 2×10^{-15} cm $^{-2}$, and the total density in both interfaces HTM and ETM are set to 10^{18} cm $^{-2}$. The results are illustrated in Figure 7.

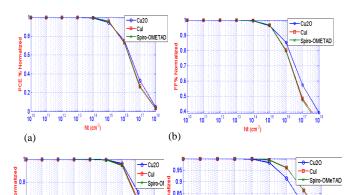
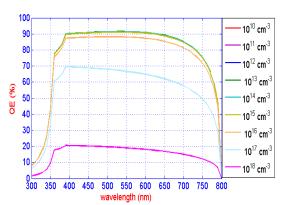


Figure 7. Variation of defect density in absorber layer on cells performance normalized: (a) PCE, (b) FF, (c) J_{sc} , (d) V_{oc} .

As it is shown in Figure 7, when the defects density is varied within the mentioned range, it can be observed that the normalized PCE falls rapidly once the defect density exceeds 2.5×1015 cm-3. It can be also determined that the normalized PCE is unchanged when the defect density is set to be less than 2.5×10¹⁵ cm⁻³ for all HTM. As defect density in the MAPbI₃ absorber layer increases from 2.5× 10¹⁵ cm⁻³ to 2.5×10¹⁸ cm⁻³, the FF reduces sharply. How-ever, the Cu₂O as hole transport material has a better performance than CuI and Spiro-OMeTAD, while the Spiro-OMeTAD and CuI have almost a similar behavior under the same condition. In addition, the FF is unchanged when the defect density is less than 2.5×10¹⁵ cm⁻³ for different HTM materials. In contrast, the J_{sc} drops significantly as the defect's density is greater than 2.5 ×1015 cm⁻³ with different HTM materials. Cu₂O has better behavior than CuI and Spiro-OMeTAD. The Jsc almost remains constant when the defects density is below 2.5×1015 cm-3 for all HTM materials. Figure 7d shows that when defects density is varied from 2.5×1015 cm⁻³ till 2.5×1018 cm⁻³, a slight reduction in V_{oc} is observed for different HTM materials in the MAPbI3 absorber layer and the Spiro-OMeTAD, CuI gives better behavior than Cu₂O. However, if the defects density is less than 2.5×10^{15} cm⁻³, the $V_{\rm oc}$ is unchanged with all HTM materials.

3.5. The effect of defects on quantum efficiency with Cu2O as HTM layer

The influence of defect density in the MAPbI $_3$ layer on the quantum efficiency of perovskite solar cells has been investigated by changing defect density from 10^{10} cm $^{-3}$ to 10^{18} cm $^{-3}$ over a range of wavelengths from 300 to 800 nm. The variation of QE with light wavelength at different defect densities is depicted in Figure 8.



It can be of about 90.2% with from 1010 cm⁻³ t

Figure 8. Quantum efficiency of PSC with a variation of defect density in the absorber layer with Cu₂O as HTM layer.

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higher than 10^{15} cm⁻³ to reach only 20% at an exponential rate. This indicates that the defects density in the CH₃NH₃PbI₃ layer of 10^{15} cm⁻³ or lower is enough to absorb most of the incident photons, and the rest does not make a significant contribution to the cell, because

the defects density affects the recombination of the photo-generated electron-hole pairs in the active layer (absorber region).

Moreover, the influence of the capture cross-section area in the MAPbI $_3$ layer on the quantum efficiency of PSCs has been studied by varying the capture cross-section area of carriers from 2×10^{-10} cm 2 to 2×10^{-18} cm 2 and computing the QE over a wavelength range from 300 nm to 800 nm as shown in figure 9.

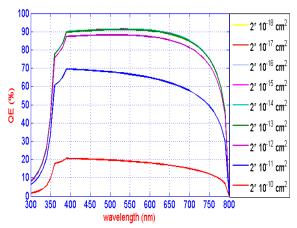
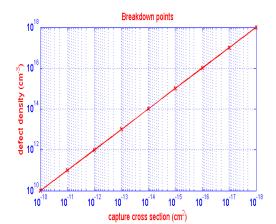


Figure 9. The quantum efficiency of PSC with a variation of capture cross-section area in absorber layer with Cu₂O as HTM layer.

As it is shown in Figure 9, the maximum quantum efficiency is approximately 90.2 % within the wavelength range of 390 nm to 650 nm, for capture cross-section area varies from 2×10^{-18} cm² to 2×10^{-13} cm². Additionally, the QE decreases rapidly, for capture cross-section area values that are greater than 2×10^{-13} cm², eventually reaching only 20% at an exponential rate. The quantum efficiency in-creases rapidly at 300 nm with a capture cross-section area of less than 2×10^{-13} cm². Then the increment slows down when the capture cross-section reaches or is lower than 2×10^{-13} cm². The capture cross-section area of the defects in the MAPbI₃ layer is sufficient to improve the performance of PSC cells.

3.6. Break down point determination of cell performance in PSC

Figure 10 illustrates the linear correlation relationship be-tween the defect density and the capture cross-section area of carriers in the absorber layer. Each point on the red line determines the value of defect density and captures cross-section area of the defect at which the cell performance breaks down. This applies to metal impurities in perovskite solar cells.



The most common impurities in MAPbI₃ material are (Au, Cu, Cr, Mo, Co, Ni) [19], where Table 3 shows the capture cross-section area of these metals. These values are taken from the literature [20]–[23].

Table 3. Capture electron and hole cross-sections of metal impurities in perovskite (CH₃NH₃PbI₃) Solar cells.

Material	σn	$\sigma_{\mathtt{p}}$	
Au	1.4×10^{-16}	7.6×10^{-15}	[20]
Cu	1.6×10^{-18}	1 ×10 ⁻¹⁹	[21]
Cr	2 ×10 ⁻¹⁴	4 ×10 ⁻¹⁵	[22]
Mo	1.6×10^{-14}	6×10^{-16}	[23]
Со	1.6 ×10 ⁻¹⁴	1×10^{-15}	[21]
Ni	5.6 ×10 ⁻¹⁷	8 ×10 ⁻¹⁷	[21]
	4×10^{-12}	1×10^{-15}	[21]

 σ_n : capture cross-section of electrons.

 σ_P : capture cross-section of holes.

From the results, it can be noticed that the capture cross-section area has a direct significant impact on the solar cell performance. In addition, the defects density has also a strong impact on the performance of PSC. However, it can be found that the value of defect density alone is not sufficient to evaluate the breakdown point of the cell performance without knowing the capture cross-section area of the defect. In contrast, the capture cross-section area alone does not give a clear image of the possible degradation of the cell's performance without knowing the defect concentration in the material. Thus, there is a strong correlation relationship between the capture cross-section area and the defects density as depicted in Figure 10. This demonstrates the importance of knowing the capture cross-section area along with the defects density precisely to determine the breakdown point of the solar cell. For example, Table 3 it is shown that the electrons capture cross-section area for gold (Au) in CH₃NH₃PbI₃ is 1.4 ×10⁻¹⁶ cm², which means that the defect density of this impurity (i.e gold) should not exceed 1.4×1016 cm-3 to avoid reaching the breakdown scenario in the performance of the solar cells, while the capture cross-section of electrons for Cu is 1.6×10⁻¹⁸ cm², poses a lower risk of breakdown than Au, due to that any defect density exceeding 2.5×10¹⁸ cm⁻³ constitutes a breakdown in the solar cell. However, Co, Cr, and Mo are considered to pose a greater risk of breakdown solar cells, which any defect density exceeding 10¹⁴ cm⁻³ results in a performance breakdown. Thus, when the defect density of a solar cell exceeds these limits, the efficiency of the cell will be rapidly decreased.

4. Conclusion

In this paper, the effect of defects concentration and the capture cross-section area of defects in the ETM, HTM, and CH₃NH₃PbI₃ layers were studied. Planer structure FTO/TiO₂/CH₃NH₃PbI₃/Cu₂O was investigated by using (SCAPS-1D). The impact of defects density and capture cross-section area in the interface layers on the performance of perovskite solar cells have also been studied. The results showed that as the defects density

sity in the CH3NH3PbI3 layer increased, the efficiency, fill factor FF, and Jsc values decreased significantly at defect density N_t greater than 1015 cm⁻³, while V_{oc} was slightly reduced. Ad-additionally, it was observed that a larger capture cross-section area $> 2 \times 10^{-14}$ cm² results in a significantly degraded cell performance and exhibits a defects density effect-like behavior. The cells' performance parameters Jsc, PCE, and FF were reduced slightly when the defects density at ETM/CH3NH3PbI3 and HTM/CH3NH3PbI3 interface layers varied from 10¹¹ cm⁻² to 10¹⁴ cm⁻² and the results also indicated that the V_{oc} has shown no change. It is demonstrated that the effect of defects density in the interface layer was negligible in comparison to the absorber layer. Moreover, from the result, it can be observed that the quantum efficiency of perovskite solar cells is sensitive to an increased defect density and capture cross-section area in the CH3NH3PbI3 layer, where the quantum efficiency is reduced sharply from 90.2% to 20% at defects density and capture crosssection areas vary from 1015 cm⁻³ to 1018 cm⁻³ and from 2×10⁻¹³ cm² to 2×10⁻¹⁰ cm², respectively. Finally, this work has introduced, for the first time, a correlation relationship between the defect density and capture cross-section area that determines the breakdown point in the cell performance.

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